





IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Wen-Yen Hwang

Serial No.:

09/820,072

Confirmation No.:

4037

Filed:

March 28, 2001

For:

Alternative Substrates for

Epitaxial Growth

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Group Art Unit:

2815

Examiner:

amoth cogni Osmallo cogni Iguyen 1-15-03 Joseph H. Nguyen

Atty. Docket No.:

PAT004US

BOX NON-FEE AMENDMENT Commissioner for Patents Washington, D.C. 20231

CERTIFICATE OF MAILING BY FIRST CLASS MAIL DATE OF DEPOSIT: December 3/, 2002

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as First Class Mail on the date indicated above and is addressed to Assistant Commissioner for Patents, Box Non-Fee Amendment, Washington, D.C. 20231-0001.

RESPONSE TO OFFICE ACTION DATED 10/08/2002

Dear Sir:

The following amendments and remarks are respectfully submitted in response to the nonfinal Office Action dated 10/08/2002.

<u>AMENDMENTS</u>

Amend the present application as follows:

IN THE SPECIFICATION

On page 3, replace the paragraph spanning lines 21-24 with the following rewritten paragraph:

--It is desirable to epitaxially fabricate a variety of types of structures or devices, using a given epi material system, grown on a given substrate. Such epitaxially fabricated devices include electronic devices, such as transistors and integrated circuits, and optoelectronic devices, such as semiconductor lasers, lightemitting diodes, and photodetectors.--



